Notice of Allowability	10/601,255 Examiner	Applicant(s) MOWERY-EVANS ET AL.
Nouce of Allowability	Examiner	
	Examiner	Art Unit
	Jonas N. Strickland	1754
The MAILING DATE of this communication app All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85 NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT R of the Office or upon petition by the applicant. See 37 CFR 1.313	o (OR REMAINS) CLOSED in) or other appropriate communities. This application is sugarded and MPEP 1308.	this application. If not included
1. $igtimes$ This communication is responsive to <u>the amendment filed</u>	on 8/26/04.	
2. ⊠ The allowed claim(s) is/are <u>claims 1-17</u> .		
3. $igotimes$ The drawings filed on <u>19 June 2003</u> are accepted by the E	xaminer.	
4. Acknowledgment is made of a claim for foreign priority uner a) All b) Some* c) None of the: 1. Certified copies of the priority documents have 2. Certified copies of the priority documents have 3. Copies of the certified copies of the priority do International Bureau (PCT Rule 17.2(a)). * Certified copies not received: Applicant has THREE MONTHS EDOM THE TAXABLE AND APPLICANT HAS THREE MONTHS ADD APPLICANT HAS ADD A	e been received. e been received in Application cuments have been received i	No in this national stage application from the
Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONM THIS THREE-MONTH PERIOD IS NOT EXTENDABLE. J. A SUBSTITUTE OATH OR DECLARATION must be submit INFORMAL PATENT APPLICATION (PTO-152) which give	itted. Note the effect of EVAN	
. CORRECTED DRAWINGS (as "replacement sheets") mus		ecial allon is delicient.
(a) ☐ including changes required by the Notice of Draftspers	on's Patent Drawing Review (PTO-948) attached
) ☐ nereto or 2) ☐ to Paper No./Mail Date		
(b) ☐ including changes required by the attached Examiner's Paper No./Mail Date	Amendment / Comment or in	the Office action of
Identifying indicia such as the application number (see 37 CED 4.)	84(c)) should be written on the o	drawings in the front (not the back) of
() as institution as such in (i)	is nearer according to 3\ CFK J	I.121(d),
 DEPOSIT OF and/or INFORMATION about the depose attached Examiner's comment regarding REQUIREMENT F 	OR THE DEPOSIT OF BIOLO	IAL must be submitted. Note the DGICAL MATERIAL.
ttachment(s)		
☐ Notice of References Cited (PTO-892)☐ Notice of Draftperson's Patent Drawing Review (PTO-948)		nal Patent Application (PTO-152)
☐ Information Disclosure Statements (PTO-1449 or PTO/SB/08	6. ☐ Interview Sumr Paper No./Ma	il Date
Paper No./Mail Date		
☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material		tement of Reasons for Allowance
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Art Unit: 1754

Allowable Subject Matter

Page 2

- 1. Claims 1-17 are allowed.
- The following is an examiner's statement of reasons for allowance: The instant 2. application is allowable over the cited prior art, because the cited prior art fails to disclose a method for catalytically reducing nitrogen oxide compounds, comprising exposing a gas comprising nitrogen oxides, consisting of NO and NO2, in the presence of NH₃ to a catalyst comprising an active component selected from CuO, Mn, and oxides of Mn on a hydrous metal oxide support.

Smirniotis et al. ("Low Temperature Selective Catalytic Reduction of NO with NH₃..") discloses a process for treating nitrogen oxides by using a hydrous metal oxide support, such as Hombikat TiO2 for NO reduction to produce a 100% yield of nitrogen gas (p. 2480, col. 1). Smirniotis et al. continues to disclose wherein the active component comprises Mn (p. 2480, col. 2). Smirniotis et al. continues to disclose wherein it is known in the art to use mixed metal oxide catalysts such as MoO₃, CuO, and MnO_x supported on TiO₂ are useful in SCR processes for reducing nitrogen oxides (p. 2480, col. 1). The gas may also comprise oxygen and water vapor (p. 2481, col. 1). The reduction of nitrogen oxides occurs at 180°C (see page 2481, col. 1). The conversion to nitrogen is 100% (see Table 1, Example 3). The oxides of Mn are comprised of MnO₂ (see Table 1, example 3). However, Hombikat TiO₂, is not the same support material as the hydrous metal oxide supports as instantly claimed. Applicant provides support in the specification disclosing the differences between the Hombikat TiO₂ support material and the hydrous metal oxide.

Application/Control Number: 10/601,255

Art Unit: 1754

Dosch et al. (US Patent 5,461,022) teaches thin film hydrous metal oxide catalysts. Dosch et al. continues to teach wherein these catalysts are useful for the reduction of nitrogen oxides (col. 2, lines 53-54). The metal oxide is preferably titanium (col. 3, lines 22-40). Dosch et al. teaches having Mo as a promoter for the catalyst and loading 1% of Mo onto the hydrous titanium oxide catalyst (col. 3, lines 45-50 and col. 8, line 15). However, Dosch et al. does not teach a catalyst comprised of CuO, Mn, and oxides of Mn.

Gardner et al. (US Patent 6,165,934) teaches a material and system for the catalytic reduction of nitrogen oxides in an exhaust gas stream wherein the catalyst is comprised of hydrous titanium oxide with a copper promoter compound (see abstract). Gardner et al. continues to teach wherein the catalyst includes silica, which allows the catalyst to be stabilized for temperatures up to 1000°C. Gardner et al. also teaches wherein the catalyst system is applied to a ceramic substrate, such as beads or a monolith, such as a cordierite honeycomb monolith (col. 1, lines 48-56). Gardner et al. does not teach wherein the catalytic active material is CuO, Mn, or Mn oxides, but rather noble metals are used as the catalytic active metals.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Jonas N. Strickland whose telephone number is 571-272-1359. The examiner can normally be reached on M-TH, 7:30-5:00, off 1st Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Stanley Silverman can be reached on 571-272-1358. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Jonas N. Strickland November 3, 2004

> STEVEN BOS PRIMARY EXAMINER GROUP 1100